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| PTO-1449 (Modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT | ATTY. DOCKET NO. 03848.80505 | SERIAL NUMBER 09/318,775 |
| | APPLICANT Calvin F. Quate, et al. | |
| | FILING DATE 5/26/99 | GROUP ART UNIT 2873 |

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| | APPLICANT Calvin F. Quate, et al. | |
| | FILING DATE 5/26/99 | GROUP ART UNIT 4743 2873 |

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| | APPLICANT Calvin F. Quate, et al. | |
| | FILING DATE 5/26/99 | GROUP A 1749 2873 |

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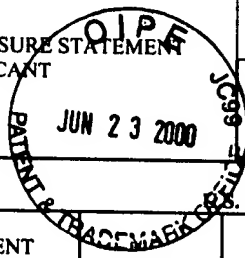
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| | 03848.80505 | 09/318,775 |
| | APPLICANT | |
| | Calvin F. Quate, et al. | |
| | FILING DATE | GROUP ART UNIT |
| | May 26, 1999 | 1743 2873 |



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